

Biography William T. Siegle

Date of birth

February 9, 1939

Nationality

US citizen

Education

Rensselaer Polytechnic Institute in Troy, New York (BSEE, MSEE and Phd.)

Career:

- **1964 - 1990 IBM**

Mr. Siegle held various technical, management and executive roles, a.o. Director of the Advanced Technology Center

- **1990 - 2005 AMD**

1990 – 1998: VP and Chief Scientist, responsible for the development of technology platforms for logic and memory platforms

1998 – 2005: SVP, responsible for AMD's world wide manufacturing operations in addition to his job as Chief Scientist.

Previous functions

Member and chairman of the Board of Directors of SRC

Member of the Board of Directors of Sematech,

Director of:

- Etec, Inc.
- DuPont Photomask, Inc.

Current functions

Member of the Advisory Board of:

- Toppan Photomasks, Inc.
- Acorn Technologies, Inc.